

EXPO Transfer Inquiry Details**Application No** 10604051**Art Unit** 2863**Class** 702**Subclass** 121000

- ☐ **Classification**
☒ **Transfer to GAU**

Request by

LE, JOHN H (#78032)

Gau***Class**

use three digits for class

Subclass**Reason****Concurred by**

(Examiner No.)

Add Transfer Inquiry**Re-Print Transfer Inquiry****Transfer History**

Transfer Inquiry	From GAU	To GAU	To Class	To Subclass	Requested By Decision By	Concurred By	Date	Reason	Status
		2863	702	121000	Docketed /		11/2/2004		
		2863	702	121000	Docketed /		10/26/2004		
		2857	702	121000	Docketed /		3/12/2004		
Transfer to 2863	2183	2863	702	155	ELLIS, RICHARD L / 69938		12/1/2003	Claimed system related to electron beam lithography mask testing. Appears to possibly be similar to 6,654,703 classified in 702/155. Possibly also class 430 as suggested.	C
Transfer to 2183	2183	2183			BERMAN, JACK I / 59199		11/21/2003	Transfer refused. Method and apparatus for evaluating product of electron beam lithography. No beam control for class 250. Try class 430.	C
Transfer to 2881	2183	2881	250	492.2	ELLIS, RICHARD L / 69938		11/4/2003	Claims relate to electron beam lithography - this has no relevance to class 712.	C